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RESPONSE UNDER 37 C.F.R. § 1.116
EXPEDITING PROCEDURE
EXAMINING GROUP 1700

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Chiu, et al. Docket No.: TSM02-1300
Serial No.: 10/608,349 Art Unit: 1763
Filed: June 27, 2003 Examiner: George A. Goudreau
For: Process For Patterning High-k Dielectric Material

Mail Stop AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

OK to enter
GAG
1-4-06

RESPONSE UNDER 37 CFR § 1.116

Applicant respectfully submits the following amendments and remarks in response to the Final Office Action dated November 10, 2004. Applicant respectfully requests that these amendments and remarks be entered in pursuant to the provisions of 37 CFR § 1.116, and respectfully request reconsideration of Claims 3-9, 11-14, 23-25, 27, and 33-36.

TSM02-1300

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Amendment